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## **AMENDMENTS**

## TO THE SPECIFICATION

Please replace the paragraph beginning on page 1, line 2 with the following amended paragraph:

--This application is a continuation-in-part application of Application Serial No. 09/124,339 filed July 29, 1998 U.S Patent No. 6,169,931 issued January 2, 2001, entitled[[,]] "Method and System for Modeling, Predicting and Optimizing Chemical Mechanical Polishing Pad Wear and Extending Pad Life".--